Polarized Electron Sources

Joe Grames



JLAB Summer Lecture Series, July 17, 2014

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Who needs electrons?

Storage batteries, man-made and natural power generators, power grids and distribution circuits, and... the "free" electrons used in particle accelerators....











Slide courtesy Prof. Steven Blusk, Syracuse University



 ^{7}Li









mass ~ $1/\lambda$ ~ energy







What to do? Build a 5 mile long electron microscope!



Make electrons energetic enough (E_{beam}) to peek inside proton or neutron ($M_{nucleon}$).





How to make the electrons "powerful" ?

Use radio(frequency) waves !!!



Continuous Electron Beam Accelerator Facility



Photo Finish, but at 2 billionths of a second !!!

DC beam, not so useful



3 lasers pulsing







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The "C" in CEBAF



Accelerators Need Electron Beams How do we make them?

- Field Emission
- Thermionic Emission
- Photoemission

The Canonical Emission Equations

(slide courtesy of Dr. K. Jensen, Naval Research Laboratory)







Fowler Nordheim E.L. Murphy, and R.H. Good, Physical Review 102, 1464 (1956).



Thermal Emission Richardson-Laue-Dushman

C. Herring, and M. Nichols, Reviews of Modern Physics 21, 185 (1949).

$$J_{RLD}(T) = A_{RLD}T^2 \exp\left(-\frac{\Phi}{k_B T}\right)$$



Photoemission Fowler-Dubridge

L.A. DuBridge Physical Review 43, 0727 (1933).

$$J_{MFD}(\lambda) = \frac{q}{\hbar\omega} (1-R) F_{\lambda}(\omega) \{\hbar\omega - \Phi\}^2 I_{\lambda}$$

Listed chronologically

Field Emitter Sources



- Explained by Fowler-Nordheim, 1928: a quantum mechanical tunneling effect
- "bright" e-beam, good for surface science



$$I \approx A \times 1.54 \times 10^{-6} \frac{F^2}{\phi} \exp\left[-6.83 \times 10^9 \frac{\phi^{3/2}}{F}\right]$$

Thermionic Emission

Used to make light....



- Studied since early 1800's and perfected over 100 years, by many inventors (why does Edison get so much credit?)
- Thermionic emission from Tungsten filaments and metalloids like LaB6 operating at >1000K are common
- ~ 90% of consumed power simply generates heat

Edison's patent, Long-lasting filament





- Melts 3695K

 Outline of Glass bulb
 Low pressure inert gas (argon, neon, nitrogen)
 Tungsten filament
 Contact wire (goes out of stem)
 Contact wire (goes into stem)
 Support wires
 Stem (glass mount)
 Contact wire (goes out of stem)
- 9. Cap (sleeve)
- 10. Insulation (vitrite)
- 11. Electrical contact

Thermionic Emission



Modern X-Ray Sources



Higher e-beam current..... Higher x-ray flux



Higher Voltage.... More penetrating x-ray beam

Courtesy Varian

CEBAF's First Electron Source

- Make beam by running current through the filament biased at 100kV
- Use "grid" to turn beam ON/OFF, i.e., create machine-safe macropulses
- Apertures to improve emittance
- Use RF "chopper" to create RF structure



Klystrons — RF generators

- Electrons make RF-energy...
- Klystrons use a DC electron beam at a few mA to generate/amplify microwaves by velocity modulation.
- Klystrons use thermionic cathodes to generate the required electron beam.





What about the probing with spin ?



Parity Violation Experiments at CEBAF

Experiment	Energy (GeV)	Ι (μΑ)	Target	A _{pv} (ppb)	Maximum Charge Asym (ppb)	Maximum Position Diff (nm)	Maximum Angle Diff (nrad)	Maximum Size Diff (δσ/σ)	
HAPPEx-II (Achieved)	3.0	55	¹ H (20 cm)	1400	400	1	0.2	Was not specified	
HAPPEx-III (Achieved)	3.484	100	¹ H (25 cm)	16900	200±100	3±3	0.5±0.1	10 ⁻³	
PREx	1.063	70	²⁰⁸ Pb (0.5 mm)	500	100±10	2±1	0.3±0.1	10-4	
QWeak	1.162	180	¹ H (35 cm)	234	100±10	2±1	30±3	10-4	
Møller	11.0	75	¹ H (150 cm)	35.6	10±10	0.5±0.5	0.05±0.05	10-4	
efferson Lab PV experiments motivate polarized e-source R&D									

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What does "234 ppb" even mean?





Electron Bunch Spin & Polarization



50% Polarization

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Polarized Source Landscape 1970s

Self-polarization via Sokolov-Ternov Effect Electron Scattering (Mott) **Photo-ionization: Fano Effect** Photo-ionization of State Selected alkali atoms **Optically Pumped He Discharge** Field Emission from EuS Photoemission from GaAs

Sources can be problematic !

- Fast spin reversal; some methods difficult to reverse spin greater than 1Hz second (present day experiments want >1kHz)
- It would be nice to make RF-time structure directly, instead of DC beam
- Most accelerators require reasonably small emittance
- Maximize feasability; lasers, pounds of alkali metal, hot and cold things very near each other, strong magnetic fields, very high voltage, challenging vacuum issues can kill a concept
- Long term reliability can be an issue (24/7 ops)
- Reproducibility, getting the same result twice

Polarized Source "Musts"

Good Photocathode

- Many electrons/photon
- High Polarization
- Fast response time



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Good Laser

- Lots of Photons
- CW Pulses
- High Polariztion



Good Electron Gun

- Accelerate Electrons
- Happy Photocathode
- Integrate Laser





GaAs....the method that caught on

PHYSICAL REVIEW B

VOLUME 13, NUMBER 12

15 JUNE 1976

Photoemission of spin-polarized electrons from GaAs

Daniel T. Pierce* and Felix Meier

Laboratorium für Festkörperphysik, Eidgenössische Technische Hochschule, CH 8049, Zürich, Switzerland (Received 10 February 1976)

The spin polarization of electrons photoemitted from (110) GaAs by irradiating with circularly polarized light of energy $1.5 < h\omega < 3.6$ eV was measured by Mott scattering. The GaAs surface was treated with cesium and oxygen to obtain a negative electron affinity (NEA). The spectrum of spin polarization $P(h\omega)$ exhibits a peak (P = 40%) at threshold arising from transitions at Γ , and positive (P = 8%) and negative (P = -8%) peaks at 3.0 and 3.2 eV, respectively, arising from transitions at L (A). Anomalous behavior, consisting of a depolarization at threshold and an increase and shift in the peak polarization to 54% at 1.7 eV, is attributed to a small positive electron affinity (PEA) characteristic of some samples. Restriction of the photoelectron emission angle by the PEA leads directly to the anomalously high P. Results of calculations show that P cannot be increased above 50% for emission arising from transitions at Γ in NEA GaAs. Our detailed interpretation of the spectra indicates how spin-polarized photoemission can be used to study the spindependent aspects of electronic structure. The outstanding qualities of NEA GaAs as a source of spinpolarized electrons are discussed and compared with other sources.

Photoemission from GaAs



Bulk GaAs

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► Laser excitation from $P_{3/2}$ to $S_{1/2}$: $E_{gap} < E_{\gamma} < E_{gap} + \Delta$

> Electron Polarization: $P_e < \frac{3-1}{3+1} = 50\%$



- σ +: Right-handed circularly polarized light σ : Left-handed circularly polarized light
- Reverse electron polarization by reversing light polarization

First Observation of Polarization from GaAs



FIG. 6. Spectrum of spin polarization from GaAs + CsOCs at $T \le 10$ K [the same sample and conditions as curve (a) of Fig. 5]. Note the high value of P=40% at threshold $(\hbar\omega \sim 1.5 \text{ eV})$ and positive and negative peaks at $\hbar\omega = 3.0$ and 3.2 eV.

First High Voltage GaAs Photogun

Polarized e⁻ Gun for SLAC Parity Violation Experiment



Started with a thermionic gun housing

First GaAs Photoinjector

- Built for SLAC parity-violation experiment E122
- Polarized electrons accelerated December, 1977
- E122 announces parity violation June, 1978 an important verification of the Standard Model



Higher P: Breaking GaAs Degeneracy

- Split degeneracy of $P_{3/2}$: Introduce strain on GaAs crystal by growing it on substrate (GaAsP) with different lattice constant
- ➤ High polarization by laser excitation from P_{3/2} to S_{1/2}: $E_{gap} < E_{\gamma} < E_{gap} + \delta$



Higher QE: Alternating layers of GaAs and GaAsP – Superlattice GaAs

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Strained layer GaAs

Bandwidth Semiconductor (formerly SPIRE)

- MOCVD-grown epitaxial spin-polarizer wafer
- Lattice mismatch

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 \Rightarrow split degeneracy of $P_{3/2}$

0.1
$$\mu$$
mStrained GaAs250 μ m $GaAs_{1-x}P_{x}$
 $x=0.29$ 250 μ m $GaAs_{1-x}P_{x}$
 $0600 μ m p -type GaAs
substrate$

Strained Layer - Superlattice GaAs



And, it really works!



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Polarized GaAs Source "Musts"

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- Fast response time



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Good Electron Gun

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Bird's Eye View



Laser Room for Dust & Climate Control







Radio Frequency Pulsed Lasers

M. Poelker, Appl. Phys. Lett. 67, 2762 (1995).



Fiber-based Drive Laser



PHYSICAL REVIEW SPECIAL TOPICS - ACCELERATORS AND BEAMS 9, 063501 (2006)

Synchronous photoinjection using a frequency-doubled gain-switched fiber-coupled seed laser and ErYb-doped fiber amplifier

J. Hansknecht* and M. Poelker

Thomas Jefferson National Accelerator Facility, 12000 Jefferson Avenue, Newport News, Virginia 23606, USA (Received 12 April 2006; published 21 June 2006)

Light at 1560 nm from a gain-switched fiber-coupled diode laser and ErYb-doped fiber amplifier was frequency doubled to obtain over 2 W average power at 780 nm with \sim 40 ps pulses and pulse repetition rate of 499 MHz. This light was used to drive the 100 kV DC high voltage GaAs photoemission gun at the



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PHYSICAL REVIEW SPECIAL TOPICS - ACCELERATORS AND BEAMS 13, 010101 (2010)

Load-locked dc high voltage GaAs photogun with an inverted-geometry ceramic insulator

P. A. Adderley, J. Clark, J. Grames, J. Hansknecht, K. Surles-Law, D. Machie, M. Poelker,* M. L. Stutzman, and R. Suleiman *Thomas Jefferson National Accelerator Facility, Newport News, Virginia 23606, USA* (Received 24 November 2009; published 26 January 2010)

A new dc high voltage spin-polarized photoelectron gun has been constructed that employs a compact inverted-geometry ceramic insulator. Photogun performance at 100 kV bias voltage is summarized.





We understand Alice's worry...



The woods-were dark and foreboding, and Alice sensed hat sinister eyes were watching her every step. Worst of all, she knew that Nature abhorred a vacuum. "The woods were dark and foreboding, and Alice sensed that sinister eyes were watching her every step. Worst of all, she knew that Nature abhorred a vacuum" – Gary Larson



Vacuum regimes

Air ~ 10¹⁶ / Torr-cm³

- Low, Medium Vacuum (>10⁻³ Torr)
 - Viscous flow
 - interactions between particles are significant
 - Mean free path less than 1 mm
- High, Very High Vacuum (10⁻³ to 10⁻⁹ Torr)
 Transition region
- Ultra High Vacuum (10⁻⁹ 10⁻¹² Torr)
 - Molecular flow
 - interactions between particles are negligible
 - interactions primarily with chamber walls
 - Mean free path 100-10,000 km
- Extreme High (<10⁻¹² Torr)
 - Molecular flow

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– Mean free path 100,000 km or greater

Vacuum Conditions at CEBAF

Application	Pressure Range	Location	Vacuum Regime	
Beamline to dumps	10 ⁻⁵ Torr	Target to dump line	Medium	
Insulating vacuum for cryogens	10 ⁻⁴ Torr to 10 ⁻⁷ Torr	Cryomodules, transfer lines	Medium to high	
Targets, Scattering Chambers	10 ⁻⁶ to 10 ⁻⁷ Torr	Experimental Halls	High to very high	
RF waveguide warm to cold windows	10 ⁻⁷ to 10 ⁻⁹ Torr	Between warm and cold RF windows	High to very high	
Warm beamline vacuum	10 ⁻⁷ to 10 ⁻⁸ Torr or better	Arcs, Hall beamline, BSY, some injector	High to very high	
Warm region girders	10 ⁻⁹ Torr or better	Girders adjacent to cryomodules	Very high to ultrahigh	
Differential pumps	Below 10 ⁻¹⁰ Torr	Ends of linacs, injector cryomodules and guns	Ultrahigh vacuum	
Baked beamline	10 ⁻¹⁰ to 10 ⁻¹¹ Torr	Y chamber, Wien filter, Pcup	Ultra high vacuum	
Polarized guns	10 ⁻¹¹ to 10 ⁻¹² Torr	Inside Polarized guns	Ultra/Extreme high vacuum	
SRF cavity vacuum	< 10 ⁻¹² Torr	Inside SRF cavities with walls at 2K	Extreme high vacuum	

Where does the gas come from?

Outgassing from the system

- Metal and non-metal (viton o-rings, ceramics) all outgas
- Primarily water in unbaked systems
- Primarily hydrogen from steel in baked systems
- Leaks
 - Real
 - Gaskets not sealed
 - Cracks in welds, bellows, ceramics, window joints
 - Superleaks that only open at very low temperatures
 - Virtual
 - Small volumes of gas trapped inside system (screw threads, etc.) that pump out slowly over time

Gas load caused by the beam

- Desorption of gases by elevated temperatures, electrons or photons striking surfaces, etc.
- Engineered Loads (targets, etc.) where gas is added
- Permeation of gasses through materials
 - Viton gaskets worse than metal seals
 - Hydrogen can permeate through stainless steel!

Ultra High Vacuum Pumps

Getter Pumps

- Chemically active surface
 - Titanium sublimed from hot filament
 - Non-Evaporative Getters
- Molecules stick when they hit
 - Does not work well for inert gasses such as Argon, Helium or for methane

Ion Pumps

- Electric field to ionize gasses
- Magnetic field to direct gasses into cathodes where they are trapped
 - Has some pumping capability for noble gasses

• Baking used to get pressures below 10⁻¹⁰ Torr

- 250°C for 30 hours removes water vapor bonded to surface that otherwise limits pressure
- Avoid contamination by oils due to roughing pumps, fingerprints, machining residue.



NEG pump array



Ion Pump

Always Tweaking the Design



Endless (?) quest for perfection







High Polarization from GaAs: Trending toward higher current...

